

## CLAIMS

What is claimed is:

1. A manufacturing method for a display device comprising:
  - a step for providing a source line around a pixel electrode provided on a substrate;
  - a step for forming an insulating film pattern having openings for a source and a drain;
  - a step for forming the source and the drain; and
  - a step for providing a semiconductor film on the source and the drain;and a step for providing a gate on the semiconductor film;
  - wherein the respective steps are implemented substantially under atmospheric pressure.
2. The manufacturing method according to Claim 1, further comprising a step for electrolytically plating the source line.
3. The manufacturing method according to Claim 1, further comprising a step for providing a film for protecting the gate and a step for applying electrophoretic ink after the film is provided.
4. The manufacturing method according to Claim 3, wherein the film is provided by laminating in the step for providing the film for protecting the gate.

6. A manufacturing method for a display device having a terminal for receiving an external signal, comprising:
  - a step for providing a protective film on a surface of the terminal;
  - a step for forming a display region with the protective film provided;
  - and a step for removing the protective film, wherein the surface of the terminal is exposed.
7. The manufacturing method according to Claim 6, wherein the protective film is a seal attached to a portion of the terminal, and the seal is peeled off and removed.
8. The manufacturing method according to Claim 6, wherein the protective film is an insulating film, and the insulating film provided on the surface of the terminal is removed by laser irradiation.
9. The manufacturing method according to Claim 6, wherein the protective film is a seal attached to the surface of the terminal, and the seal is heated to generate a gas, which causes the seal to be peeled off and removed.